

## EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	83	((opening or window or hole or via or groove or aperture or housing or gap or container or trench or cavity or notch) with ((plural or twice or double or few or several or "more than one" or "more-than-one") with (PR or photoresist or "photo resist" or "photo-resist" or photomask\$ or "photo mask" or "photo-mask" or photolithogra\$))).clm.	US-PGPUB; USPAT	OR	ON	2006/09/30 18:03
L2	6283	((438/694) or (438/695) or (438/700) or (438/702) or (438/703) or (438/743) or (438/744) or (438/756) or (438/757) or (438/761) or (438/778) or (438/942) or (438/946)).CCLS.	US-PGPUB; USPAT	OR	OFF	2006/09/30 18:05
L3	3	1 and 2	US-PGPUB; USPAT	OR	ON	2006/09/30 18:05
L4	4508858	@ad<"20040220"	US-PGPUB; USPAT	OR	ON	2006/09/30 18:05
L5	3	3 and 4	US-PGPUB; USPAT	OR	ON	2006/09/30 18:07

## EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	68	((resist or PR or photoresist or "photo resist" or "photo-resist") with (SiON or "silicon-oxynitride" or "silicon oxynitride" or "silicon oxy nitride" or "silicon-oxy-nitride")) with mask).clm.	US-PGPUB; USPAT	OR	ON	2006/09/30 18:08
L2	4508858	@ad<"20040220"	US-PGPUB; USPAT	OR	ON	2006/09/30 18:09
L3	62	1 and 2	US-PGPUB; USPAT	OR	ON	2006/09/30 18:09
L4	13	((resist or PR or photoresist or "photo resist" or "photo-resist") with (SiON or "silicon-oxynitride" or "silicon oxynitride" or "silicon oxy nitride" or "silicon-oxy-nitride")) with (mask with (opening or window or via or hole or aperture or groove or gap or housing or recess))).clm.	US-PGPUB; USPAT	OR	ON	2006/09/30 18:10
L5	13	2 and 4	US-PGPUB; USPAT	OR	ON	2006/09/30 18:10